; 2006	16 m PTO-1595 93	06-02		U.S. Department of Commerc Patent and Trademark Offic
5.26.06	OMB No. 0651-0011 (exp. 4/94)	I-0011 (exp. 4/94)		
	To the Honorable Commissioner of Patents and Tra	103249342 1032itached original documents or copy thercof.		cof.
	 Name of conveying party(ies): Ralf Siemieniec Hans-Joachim Schulze Franz Hirler Additional name(s) of conveying party(ies) attached? [] Nature of Conveyance: [X] Assignment [] Merger [] Security Agreement [] Change of [] [] Other Execution Date(s): 03/24/06; 05/04/06; 0 	of Name	 Name and address of rece Name: <u>Infineon Technologi</u> Street Address: <u>Siemensstra</u> City: <u>9500 Villach</u> Country: <u>Austria</u> Additional name(s) & addres 	es Austria AG
	 4. Application number(s) or patent number(s): If this document is being filed together with a new application, the execution date of the application is A. Patent Application No(s) 11/364,882 B. Patent No(s) 			
	Title of Invention: Method for Producing a Buried Semiconductor Layer Our Docket No.: 1890-0357			
	 Name and address of party to whom corre concerning document should be mailed: 	espondence	6. Total number of applicati	ons and patents involved <u>1</u>
	Name: <u>Harold C. Moore</u>		7. Total fee (37 CFR 3.41):	.\$ <u>40.00</u>
	Internal Address: Maginot, Moore & Beck		[X] Enclosed [] Authorized to be charged to deposit account	
	Street Address: <u>111 Monument Circle, Suit</u> City: State: Zip: <u>Indianapolis, IN 46204-51</u>		8. Deposit Account number	: 13-0014
			(Attach duplicate copy of this pa	ge if paying by deposit account)
	DO NOT USE THIS SPACE			
	9. Statement and signature. To the best of my knowledge and belief, the foregoing information is true and correct and any attached copy is true copy of the original document. Harold C. Moore May 24, 2006 Name of Person Signing Signature Registration No. 37,892 Total number of pages including cover sheet, attachments and document			
	Mail documents to be recorded with required cover sheet information to:			

05/30/2006 SSITHIB1 00000062 11364882 01 FC:8021 (40.00 DP

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PATENT REEL: 017930 FRAME: 0475

INFINEON REF NO.13.921 MMB REF NO.1890-0357

ASSIGNMENT

For good and valuable consideration, I, Ralf Siemieniec, a citizen of Germany, residing at Litzelhofenstr. 8, 9500 Villach, Austria, Hans-Joachim Schulze, a citizen of Germany, residing at Ottostr. 60f, 85521 Ottobrunn, Germany, and Franz Hirler, a citizen of Germany, residing at Mozartstr. 4, 84424 Isen, Germany, hereinafter individually or collectively referred to as "Assignor";

Hereby sell, assign and transfer to Infineon Technologies Austria AG, a corporation organized and existing under the laws of Austria, having its principal place of business at Siemensstrasse 2, 9500 Villach, Austria, hereinafter "Assignee", its successors, assigns and legal representatives, the entire right, title and interest in and for the United States and all foreign countries, in and to any and all improvements which are disclosed in the application for United States Letters Patent, Serial No. <u>11/364,882</u>, filed on <u>February 28, 2006</u> and

entitled: METHOD FOR PRODUCING A BURIED SEMICONDUCTOR LAYER

and in and to said application and all divisional, continuing, substitute, renewal, reissue, and all other applications for Letters Patent which have been or shall be filed in the United States and all foreign countries on any of said improvements; and in and to all original and reissued patents which have been or shall be filed in the United States and all foreign countries on said improvements;

Agree that said Assignee may apply for and receive Letters Patent for said improvements in its own name; and that, when requested, without charge to but at the expense of said Assignee, its successors, assigns and legal representatives, to carry out in good faith the intent and purpose of this assignment, the undersigned will execute all divisional, continuing, substitute, renewal, reissue, and all other patent applications on any and all said improvements; execute all rightful oaths, assignments, powers of attorney and other papers; communicate to said Assignee, its successors, assigns, and legal representatives, all facts known to the undersigned relating to said improvements an the history thereof; and generally do everything possible which said Assignee, its successors, assigns or legal representatives shall consider desirable for aiding in securing and maintaining proper patent protection for said improvements and for vesting title to said improvements and all applications for patents and all patents on said improvements, in said Assignee, its successors, assigns and legal representatives; and emprovements, in said Assignee, its successors, assigns and legal representatives; and

Covenant with said Assignee, it successors, assigns and legal representatives that no assignment, grant, mortgage, license or other agreement affecting the rights and property herein conveyed has been made to others by the undersigned, and that full right to convey the same as herein expressed is possessed by the undersigned.

SIGNATURE:

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DATE: 24.03.2006

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NAME: Ralf Siemieniec

SIGNATURE:

NAME: Hans-Joachim Schulze

SIGNATURE:

NAME: Franz Hirler

DATE:

DATE:

PATENT REEL: 017930 FRAME: 0476

INFINEON REF NO.13.921 MMB REF NO.1890-0357

ASSIGNMENT

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Agree that said Assignee may apply for and receive Letters Patent for said improvements in its own name; and that, when requested, without charge to but at the expense of said Assignee, its successors, assigns and legal representatives, to carry out in good faith the intent and purpose of this assignment, the undersigned will execute all divisional, continuing, substitute, renewal, reissue, and all other patent applications on any and all said improvements; execute all rightful oaths, assignments, powers of attorney and other papers; communicate to said Assignee, its successors, assigns, and legal representatives, all facts known to the undersigned relating to said improvements an the history thereof; and generally do everything possible which said Assignee, its successors, assigns or legal representatives shall consider desirable for aiding in securing and maintaining proper patent protection for said improvements and for vesting title to said improvements and all applications for patents and all patents on said improvements, in said Assignee, its successors, assigns and legal representatives; and

Covenant with said Assignee, it successors, assigns and legal representatives that no assignment, grant, mortgage, license or other agreement affecting the rights and property herein conveyed has been made to others by the undersigned, and that full right to convey the same as herein expressed is possessed by the undersigned.

SIGNATURE:

NAME: Ralf Siemieniec

DATE:

DATE:

SIGNATURE:

Han Jocel Bluke

NAME: Hans-Joachim Schulze

SIGNATURE:

NAME: Franz Hirler

PATENT REEL: 017930 FRAME: 0477

DATE: 4.5-06

INFINEON REF NO.13.921 MMB REF NO.1890-0357

ASSIGNMENT

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Agree that said Assignee may apply for and receive Letters Patent for said improvements in its own name; and that, when requested, without charge to but at the expense of said Assignee, its successors, assigns and legal representatives, to carry out in good faith the intent and purpose of this assignment, the undersigned will execute all divisional, continuing, substitute, renewal, reissue, and all other patent applications on any and all said improvements: execute all rightful oaths, assignments, powers of attorney and other papers; communicate to said Assignee, its successors, assigns, and legal representatives, all facts known to the undersigned relating to said improvements an the history thereof; and generally do everything possible which said Assignee, its successors, assigns or legal representatives shall consider desirable for aiding in securing and maintaining proper patent protection for said improvements and for vesting title to said improvements and all applications for patents and all patents on said improvements, in said Assignee, its successors, assigns and legal representatives; and

Covenant with said Assignee, it successors, assigns and legal representatives that no assignment, grant, mortgage, license or other agreement affecting the rights and property herein conveyed has been made to others by the undersigned, and that full right to convey the same as herein expressed is possessed by the undersigned.

SIGNATURE:

NAME: Ralf Siemieniec

SIGNATURE:

NAME: Hans-Joachim Schulze

SIGNATURE:

NAME: Franz Hirler

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DATE:

DATE:

DATE: 2006-03-26

PATENT REEL: 017930 FRAME: 0478

RECORDED: 05/26/2006